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January 2, 2006

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Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

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Re: Serial No.: 10/717,814  
Downhole Seal Element Formed From a Nanocomposite Material  
Art Unit: 3672  
Confirmation No.: 9717  
Examiner: Daniel P. Stephenson  
Our File: 1301-1161


Dear Sir:

Enclosed for filing please find the following item (6 + 1 pages) relating to the above-identified application:

- (1) Response Under 37 CFR 1.111 (6 pages).

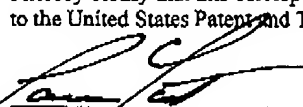
If you have any questions or comments concerning this matter, please call the undersigned at your earliest convenience. Otherwise, please accept the enclosed.

Sincerely,

  
Lawrence R. Youst  
Reg. No. 38,795  
Enclosures

Certificate of Transmission Under 37 C.F.R. §1.8

I hereby certify that this correspondence is being transmitted by facsimile to the United States Patent and Trademark Office on January 2, 2006.

  
Lawrence R. Youst

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**JAN 02 2006**

Attorney Docket No.: 1301-1161  
Halliburton Docket No.: 2003-IP-012730 U1 USA

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Re Application: Jeremy Buc Slay et al.

Serial No. 10/717,814

Filed: November 20, 2003

Art Unit: 3672

Confirmation No.: 9717

Examiner: Daniel P. Stephenson

For: Downhole Seal Element Formed From a  
Nanocomposite Material

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**Response Under 37 C.F.R. §1.111**

Dear Sir:

This is a response to the Office Action dated December 2, 2005, which is due for reply by January 2, 2006. In view of the following remarks, allowance of the claims pending in this application is respectfully requested.